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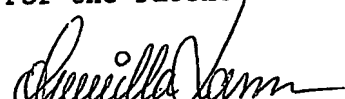
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(21) Patentansökningsnummer 0303281-0
Patent application number

(86) Ingivningsdatum 2003-12-05
Date of filing

Stockholm, 2004-12-09

För Patent- och registreringsverket
For the Patent- and Registration Office


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NEW METALLIC STRIP MATERIAL

The present invention relates to a method of manufacturing a metal oxide coated metal strip product in a roll-to-roll process and in particular to a coated metallic substrate material suitable for manufacturing of thin film devices. This is achieved by producing a
5 metallic strip with an electrically insulating oxide layer, in accordance with claim 1.

Background of the Invention

Several materials are used as substrate material and are under further development for the production of thin film flexible products. There exist several advantages to use
10 flexible substrate materials, one being the possibility of roll-to-roll production processes, which lead to a more cost efficient production compared to batch type processes. Moreover, the thin film flexible products will have several technical advantages, for instance, they may be folded or rolled into compact packages and they may be used for making light weight products, which are required for portable, spatial
15 and military applications. The common materials used for thin film flexible products include, e.g., plastic foils such as polyamide, metallic strips or foils such as stainless steel, titanium, copper, molybdenum, aluminum and nickel foils, bearing in mind that they all have to fulfil certain criteria. Thus, the substrate material should be thermally resistant in order to withstand further process steps in the production of thin film
20 products, and this may include heat treatments at elevated temperatures under corrosive atmosphere. However, all the electrical conducting metallic strip materials used as substrate material for the production of thin film flexible products may need to be electrically insulated, if modules with integrated series connections are to be produced. Conventionally, the conducting metallic strip or foil material is coated with oxides such
25 as aluminum oxide or silicon oxide, which are good electrical insulating oxides. However, these oxide layers usually have a large mismatch in the thermal expansion compared with the underlying metallic substrate. Thus, it is essential that the thermal expansion coefficient (TEC) of the substrate material should be as close as possible to the TEC of the electrically insulating metal oxide layer(s), in order to avoid thermal
30 cracking or spallation of the insulating metal oxide layer.

The mismatch in thermal expansion (MTE) can be defined as follows: $(TEC_{ss} - TEC_{ox})/TEC_{ss}$ where the TEC_{ss} is the thermal expansion of the metallic strip substrate and TEC_{ox} is the thermal expansion of the metal oxide layer.

- 5 Ferritic stainless steels and yttrium-stabilized zirconia (abbreviated YSZ) are two materials commonly used in the fabrication of Solid Oxide Fuel Cells because these two materials have an extremely low mismatch in their thermal expansion. However, the YSZ in Solid Oxide Fuel Cells are not in the form of a thin coating but in the form of a thin plate, which is used as an electrolyte.
- 10 Common conventional solutions are:
- Depositing the electrically conducting back contact directly onto the metallic strip;
 - Depositing insulating layers such as aluminum oxide, silicon oxide and silicon nitride onto metal strips,
- 15 Both these solutions have their respective disadvantages. If the conducting back contact is directly deposited onto the flexible metal strip substrate, then it will limit the production of modules with integrated series connections. Furthermore, the material often used as insulating layers, such as Al_2O_3 , Si_3N_4 , SiO_x or SiO_2 , have a larger TEC mismatch with the underlying metallic strip, which may lead to the formation of cracks
- 20 and pinholes due to heating during the following process steps. In table 1 the thermal expansion coefficients of some insulating materials and some steels have been summarized. Using the values of the thermal expansions given in Table 1, it is possible to calculate the thermal expansion mismatch (MTE) between the metallic strip substrate and the insulating coating. In Table 2 the MTE values between some of the steels and
- 25 the listed insulating materials are given.
- It is therefore a primary object of the present invention to provide a zirconium oxide coated metallic strip product, where the oxide layer and the metallic strip have a very low mismatch in thermal expansion, said product being suitable as a substrate material
- 30 for the production of thin film flexible products, such as flexible $Cu(In,Ga)Se_2$ (abbreviated CIGS) solar cells and solid state thin film batteries.

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Yet another object of the present invention is to provide a flexible substrate for thin film products that is inexpensive and which may be produced in a continuous roll-to-roll process.

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These and other objects have been attained in a surprising manner by creating a coated metallic strip product with the features according to the characterizing clause of claim 1. Further preferred embodiments are defined in the dependent claims.

10 Brief Description of the Invention

Thus, the above objects and further advantages are achieved by applying a thin continuous, uniform, electrically insulating layer of zirconia, the zirconia being stabilized with yttrium oxide or any other suitable metal oxide, on the top of a metal strip serving as substrate. The absolute composition of the zirconia layer can be tailor-

15 made so that the thermal expansion matches the thermal expansion of the chosen metallic strip substrate. The zirconia layer should be smooth and dense in order to avoid any pinholes, which may otherwise function as pathways for electrical conduction when the material is further processed. In order to ensure safe electrical insulation from the metal strip substrate, multi-layers (ML) of zirconia can be deposited. The advantage of a

20 ML structure is that it will terminate any pinholes or conducting pathways through the insulating oxide layers. Furthermore, by depositing a continuous uniform dense zirconia layer on top of the metallic substrate, it is easier to control the insulating properties as well as the thickness of the zirconia layer, compared to for instance anodized oxide layers on metallic strips. Moreover, the zirconia layer will also have an enhanced

25 adhesion to the substrate, in comparison with thermally grown oxide layers. If needed, the zirconia layer may be deposited on both sides of the strip material, in order to totally eliminate any curling of the coated strip during heat treatments due to any small thermal expansion differences.

30

Further, if so required, on top of said zirconia layer may then be deposited a metal layer, this for obtaining a back electrical contact. If the final product is a CIGS flexible thin

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film solar cell, then this metal should be molybdenum. However, if the final product is a thin film battery, this metal back contact may be aluminum or copper.

5

Brief Description of the Drawings

Figure 1 shows a schematic cross-section of a first embodiment of the present invention.

Figure 2 shows a schematic cross-section of a second embodiment of the present invention.

10 Figure 3 shows a schematic cross-section of a third embodiment of the present invention.

Figure 4 shows a schematic cross-section of fourth embodiment of the present invention.

15 Figure 5 shows schematically a production line for the manufacturing of a coated metal strip material according to the invention.

Detailed Description of the Invention

20 The Metal Strip to be coated

The metal strip to be coated can be any metallic strip material with a low thermal expansion mismatch with the zirconia coating, preferably a stainless steel and most preferably a ferritic chromium steel. Such steel substrate materials are produced by ordinary metallurgical steel making with a chromium content of at least 10% b.w.

25 suitably more than 14% b.w., and most preferably in the range 16 - 25% b.w. Some examples of possible steel substrates are grade ASTM 430 with a chromium content of 16 % b.w., and the Sandvik grade 0C404 with a chromium content of 20 % b.w., and an aluminum content of 5.5 % b.w. The ferritic strip is hot rolled down to an intermediate size, and thereafter cold-rolled in several steps with a number of recrystallization steps

between said rolling steps, until a final thickness and a width of maximally 1000 mm are achieved. Another important parameter is the surface roughness of the metal strip, which should be as smooth as possible; a Ra value of less than 0,2 μm is suitable, preferably less than 0,1 μm . The surface of the substrate material is then cleaned in an appropriate way to remove all oil residuals from the rolling. The key issue for using a ferritic steel is that its thermal expansion coefficient (TEC) matches very well with the deposited zirconia coating, although other steel types fulfilling this criterion are also useful. Thus, it is desirable that the thermal expansion mismatch of the metallic strip substrate and the zirconia coating is lower than $\pm 25\%$ in the temperature range up to 1000°C. Furthermore, ferritic steels have also a very good corrosion resistance to withstand the environment in which the final thin film product will work. The physical shape of the metallic substrate is a strip or foil with a thickness in the range of 5 to 300 μm , preferably 10 to 100 μm .

15 The Insulating Zirconia Layer

The electrically insulating zirconia layers should adhere well to the metallic strip, in order to ensure highest possible flexibility of the thin film product without the zirconia layer flaking off or cracking. This is achieved by careful pre-treatment of the metal strip prior to the coating, first by cleaning it in a suitable way to remove all oil residues, etc., which may affect the efficiency of the coating process, and the adhesion and quality of the coating. Thereafter, the metal strip is treated by means of an in-line ion assisted etching process and, if necessary, a thin bond-coat layer may be deposited between the metal strip and the zirconia layer. Preferably, the bond-coat should consist essentially of a metal such as Ti, Zr, Ni or Cr, to enhance the adhesion of the zirconia layer to the substrate. Moreover, the zirconia layer should also be a good electrical insulator in order to avoid any electrical connection between the metallic strip and the molybdenum (or Al or Cu) back contact. This can be achieved by depositing a dense and smooth zirconia layer to bring about better insulating properties, it possibly being repeated so that multi-layered structures are deposited. The number of individual zirconia layers in a multi-layered structure can be 10 or less, preferably less than 5 and at best only two layers. As mentioned above, a multi-layered zirconia structure will terminate any pinholes or

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electrical pathways through the overall metal oxide layer and ensure good electrical insulation of the metallic strip. The thickness of each individual zirconia layer may be between 10 nm and 2 μm , preferably between 0,1 and 1,5 μm . The total thickness of the overall zirconia layer may be up to 20 μm , preferably 0,5 to 5 μm .

5

The preferred chemical composition of the zirconia layer is ZrO_2 stabilized with Y_2O_3 , the percentage of Y_2O_3 in the zirconia can be from 0 - 25% b.w., preferably 3 - 20% b.w., or most preferably 5 -15% b.w., although other stabilizing metal oxides are feasible (both stoichiometric and non-stoichiometric).

10

Description of Back Contact Layer

When required, a top conducting metallic layer can be applied on top of the insulating zirconia layer. Depending on the final thin film product, different metals may be deposited, including aluminum, molybdenum, nickel, cobalt, copper, silver, gold and platinum. This metallic top layer should be dense and adhere well to the underlying, previously deposited oxide layer. The thickness of this metallic layer should be 0,01-5,0 μm .

Description of Coating Method

20 A broad variety of coating techniques may be used as long as they provide a continuous uniform and adherent layer. These may be techniques such as spraying, High Velocity Oxygen Fuel (HVOF), dipping, Physical Vapor Deposition (PVD), Chemical Vapor Deposition (CVD) or any other known technique for applying a fluid gel or powder of a Zr-containing compound on the surface of the ferritic steel, preferably by PVD in a roll-
25 to-roll Electron Beam Evaporation (EB) process as disclosed in WO 98/08986. If necessary, the PVD process can also be plasma-activated to achieve even better insulating oxide layers. It is also possible to apply the coating in the form of a fine grain powder. The conditions for applying and forming the zirconia layer on the surface may have to be determined experimentally for each individual case. The coating will be
30 affected by factors such as temperature, time drying, time heating, composition and properties, as well as by the ferritic steel and the Zr-containing compound.

Another important issue is that the metallic strip substrate is cleaned in a proper way to remove oil residues etc. from the rolling, which may affect the efficiency of the coating process and the adhesion and quality of the zirconia coating.

5

Advantageously, the coating method is integrated in a conventional roll-to-roll strip production line.

Preferred Embodiment of the Invention

- 10 Firstly, the substrate materials are produced by ordinary metallurgical steel-making to a chemical composition as described above. Subsequently, they are hot-rolled down to an intermediate size, and thereafter cold-rolled in several steps with a number of recrystallization steps between said rolling steps, until a final thickness of 0,005 – 0,3 mm and a width of maximally 1000 mm are achieved. The surface of the substrate
- 15 material is then cleaned in a proper way to remove all oil residuals from the rolling.

- In Figure 1, a typical cross section of a zirconia coated flexible ferritic steel 1 is shown, one side of which has been coated with a YSZ layer 3 for the production of thin film products. The substrate material 2 is a flexible ferritic steel strip, which has a thermal
- 20 expansion mismatch lower than $\pm 25\%$ with the zirconia coating in the temperature range 0-1000 °C. The surface roughness of the ferritic steel strip should be kept as low as possible. The thickness of the ferritic steel should be in the range of 5 - 300 μm , preferably 10-100 μm , to ensure good flexibility.

- On top of the surface of the ferritic steel strip 2 is situated an electrically
- 25 insulating yttrium stabilized zirconia layer 3 deposited in a roll-to-roll process. The yttrium stabilized zirconia layer should be well adherent to the metal strip, as well as dense and smooth.

- In a variation of the above described flexible metallic substrate being coated on one side
- 30 only with YSZ, also the other side of the metallic strip may be coated with YSZ, to produce a product 4, which is illustrated in Figure 2. In the Figure 2, the substrate

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material 2 has been coated on both sides with YSZ 3 and the two YSZ layers 3 should have the same thickness to achieve a total elimination of any thermal deformation of the coated strip due to the YSZ coatings in further process steps.

- 5 According to a further variation of the invention, the strip product 5 consists of a flexible metallic strip 2 coated with a multi-layer structure 6 of YSZ, as illustrated in Figure 3. The number of individual zirconia layers in the multi-layered structure 6 can be 10 or less, preferably less than 5 and at best only two layers. As mentioned before, a multi-layered zirconia structure will terminate any pinholes or electrical pathways
- 10 through the overall metal oxide layer and ensure good electrical insulation of the metallic strip. The thickness of each individual zirconia layer may be between 10 nm and up to 2 μm , preferably between 0,1 and 1,5 μm . The total thickness of the overall zirconium oxide layer may be up to 20 μm , preferably 1 to 5 μm .
- 15 In order to create a conducting back contact for the production of thin film products, a metal layer 7 can be deposited on top of the electrically insulated, YSZ-coated (8) ferritic steel strip 2, as illustrated in Figure 4. Depending on the final thin film product, the metal layer 7 can consist of different metals, including aluminum, molybdenum, nickel, cobalt, copper, silver, gold and platinum; the preferred metal being aluminum,
- 20 molybdenum, silver and/or copper, or alloys consisting mainly of molybdenum. The metal layer 7 should be dense and well adherent to the zirconia coating to avoid cracking or spallation. Furthermore, the metal layer 7 should have a thickness of between 0,1 – 5 μm , preferably 0,2 – 2 μm , and most preferably around 0,5 μm .
- 25 The roll-to-roll electron beam evaporation process is illustrated in Figure 5. This process is well known for the skilled man and is, e.g., comprehensively described in the book Electron Beam Technology by Siegfried Schiller, Ulrich Heisig and Siegfried Panzer, Verlag Technik GmbH Berlin 1995, ISBN 3-341-01153-6, hereby incorporated into the present disclosure by this reference. The first part of such a production line is the
- 30 uncoiler 9 within a vacuum chamber 10, then the in-line ion assisted etching chamber 11, followed by a series of EB evaporation chambers 12, the number of EB evaporation

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chambers needed can vary from 1 up to 10 chambers, this to achieve the wanted multi-layered metal oxide structure. All the metal oxide EB evaporation chambers 12 are equipped with EB guns 13 and crucibles 14 for the evaporation. The following chamber is a separate chamber 15 for the EB evaporation of a metal top layer, this chamber is also equipped with an EB gun 16 and a crucible 17 for the metal melt. The need for a separate EB evaporation chamber for the metal top layer can be excluded if only metal oxide coated strips are to be produced. After this chamber comes the exit vacuum chamber 18 and the recoiler 19 for the coated strip material, the recoiler being located within vacuum chamber 18. The vacuum chambers 10 and 18 may also be replaced by an entrance vacuum lock system and an exit vacuum lock system, respectively. In the latter case, the uncoiler 9 and the coiler 19 are placed in the open air.

Table 1.

Material	Temperature Range	Thermal Expansion
Si ₃ N ₄ (□)	25-1000 K	2.9x10 ⁻⁶ K ⁻¹
Si ₃ N ₄ (□)	25-1000 K	2.25x10 ⁻⁶ K ⁻¹
Al ₂ O ₃ (polycryst.)	0-1027 °C	8.12x10 ⁻⁶ K ⁻¹
TiO ₂ (polycryst.)	25-1000 °C	8.83x10 ⁻⁶ K ⁻¹
SiO ₂ (vitreous)	25-1000 °C	0.564x10 ⁻⁶ K ⁻¹
YSZ	25-1000 °C	11x10 ⁻⁶ K ⁻¹
Fe ₈₀ Cr ₂₀	25-1000 °C	13.5x10 ⁻⁶ K ⁻¹
Fe ₇₀ Cr ₃₀	25-1000 °C	13.0x10 ⁻⁶ K ⁻¹
Sandvik grade 0C44	30-900 °C	11.10x10 ⁻⁶ K ⁻¹
ASTM 430	30-900 °C	12.05x10 ⁻⁶ K ⁻¹
St1.4016	25-1000 °C	13.2x10 ⁻⁶ K ⁻¹
St1.4742	25-1000 °C	14.3x10 ⁻⁶ K ⁻¹
St1.4749	25-1000 °C	13.7x10 ⁻⁶ K ⁻¹

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Table 2

Steel	Insulating layer	Calculated MTE (%)
St1.4016	SiO ₂	95.7%
St1.4016	Si ₃ N ₄ (□)	78%
St1.4016	Al ₂ O ₃	38%
St1.4016	TiO ₂	33%
St1.4016	YSZ	16.7%
Fe ₈₀ Cr ₂₀	SiO ₂	96%
Fe ₈₀ Cr ₂₀	Si ₃ N ₄ (□)	78.5%
Fe ₈₀ Cr ₂₀	Al ₂ O ₃	40%
Fe ₈₀ Cr ₂₀	TiO ₂	35%
Fe ₈₀ Cr ₂₀	YSZ	19%
0C44	SiO ₂	95%
0C44	Si ₃ N ₄ (□)	74%
0C44	Al ₂ O ₃	27%
0C44	TiO ₂	20%
0C44	YSZ	1%
St1.4742	SiO ₂	80%
St1.4742	Si ₃ N ₄ (□)	96%
St1.4742	Al ₂ O ₃	43%
St1.4742	TiO ₂	38%
St1.4742	YSZ	23%

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CLAIMS

1. A metallic strip product comprising a metallic strip material (2), characterized in that said strip material has a coating (3; 6; 8) comprising an electrically insulating layer of zirconia.

2. Coated strip product according to claim 1, characterized in that said coating and strip material have a thermal expansion mismatch of less than $\pm 25\%$ where the thermal expansion mismatch is defined as:

$$(TEC_{ss} - TEC_{ox}) / TEC_{ss}$$

where the TEC_{ss} is the thermal expansion of said strip material and TEC_{ox} is the thermal expansion of said zirconia-containing coating.

3. Coated strip product according to claim 1 or 2, characterized in that the strip material has a thickness of 5 to 300 μm , preferably 10 to 100 μm .

4. Coated strip product according to claim 1, 2 or 3, characterized in that a ferritic chromium strip steel material is used as the metallic strip material to be coated.

5. Coated strip product according to claim 4, characterized in that said ferritic chromium strip steel material has a chromium content of at least 10% b.w., suitably at least 14% b.w., and preferably in the range 16 - 25% b.w.

6. Coated strip product according to any of claims 1 to 5, characterized in that the electrically insulating layer comprises at least one zirconia layer (3; 6; 8) deposited on one or both sides of the metallic strip material.

7. Coated strip product according to any of claims 1 to 6, characterized in that the metal oxide layer consists essentially of zirconium oxide, ZrO_2 .

8. Coated strip product according to any of claims 1 to 7, characterized in that the metal oxide layer consists essentially of stabilized zirconia, preferably yttrium stabilized zirconia (YSZ) with a percentage of Y_2O_3 in the range from 0 - 25% b.w. of said layer, suitably 3 - 20% b.w., preferably 5 - 15% b.w.

9. Coated strip product according to any of the preceding claims, characterized in that the thickness of the stabilized zirconia is between 0,1 and 20 μm , preferably between 0,5 and 5 μm .

10. Coated strip product according to any of the preceding claims, characterized in that between the stabilized zirconia layer and the metallic strip material a thin layer of a bond-coat is deposited, preferably a bond-coat of a metal such as Ti, Zr, Ni or Cr, to enhance the adhesion of the zirconia layer to the substrate.

11. Coated strip product according to any of the preceding claims, characterized in that on top of the electrically insulating stabilized zirconia layer a conducting metal layer is deposited, the metal layer consisting preferably of one of the following metals: aluminum, molybdenum, nickel, cobalt, copper, silver, gold and platinum, most preferably aluminum, molybdenum, silver or copper.

12. Coated strip product according to claim 11, characterized in that the metal top layer has a thickness of between 0,01 and 5 μm .

13. Coated strip product according to any of the preceding claims characterized in that the electrically insulating layer(s) is/are deposited by any known deposition technique, including different spray techniques such as HVOF, plasma spraying, as well as vapor deposition techniques such as Chemical Vapor Deposition (CVD), Physical Vapor Deposition (PVD), dipping techniques, sol-gel techniques, preferably PVD in a roll-to-roll electron beam (EB) evaporation process.

14. Coated strip product according to any of the preceding claims, characterized in that it is suitable as substrate material for the production of flexible thin film products such as flexible Cu(In,Ga)Se_2 (CIGS) solar cells and solid state thin film batteries.
- 5 15. Coated strip product according to claim 14, characterized in that it is used as substrate material for the production of flexible thin film Cu(In,Ga)Se_2 (CIGS) solar cells, the conducting metal layer deposited on top of the electrically insulating stabilized zirconia layer being essentially molybdenum.
- 10 16. Coated strip product according to claim 14, characterized in that it is used as substrate material for the production of solid state thin film batteries, the conducting metal layer deposited on top of the electrically insulating stabilized zirconia layer being essentially copper and/or aluminum.



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ABSTRACT

A flexible metallic strip product comprises a ferritic chromium strip steel material (2) having a coating (3; 6; 8) of an electrically insulating layer of zirconia stabilized with yttrium, said coating being intended to receive a second coating (7) comprising an electrically conducting layer. This coating has turned out to be very efficient as an electrically insulating layer in flexible solar cells and solid state thin film batteries because it has practically the same thermal expansion coefficient as the steel substrate.

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Publication picture: Figure 1

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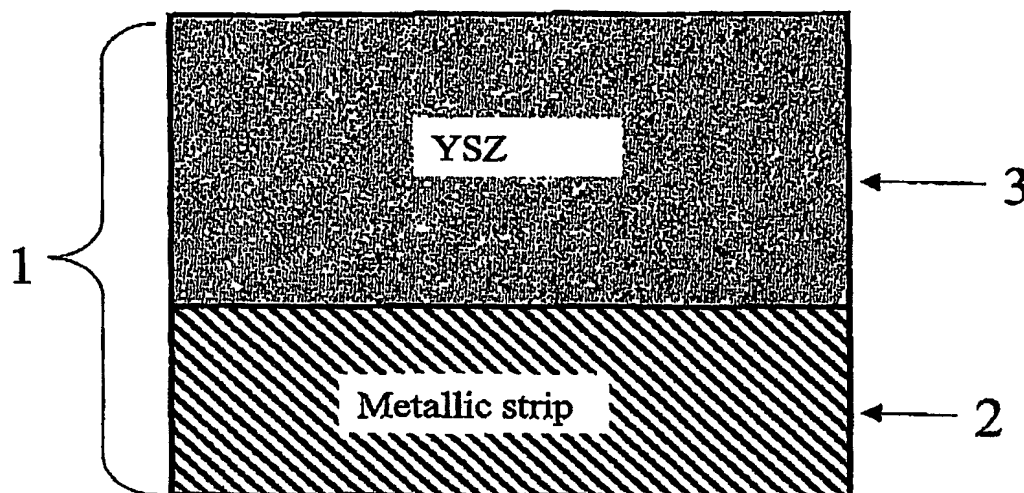


Fig. 1

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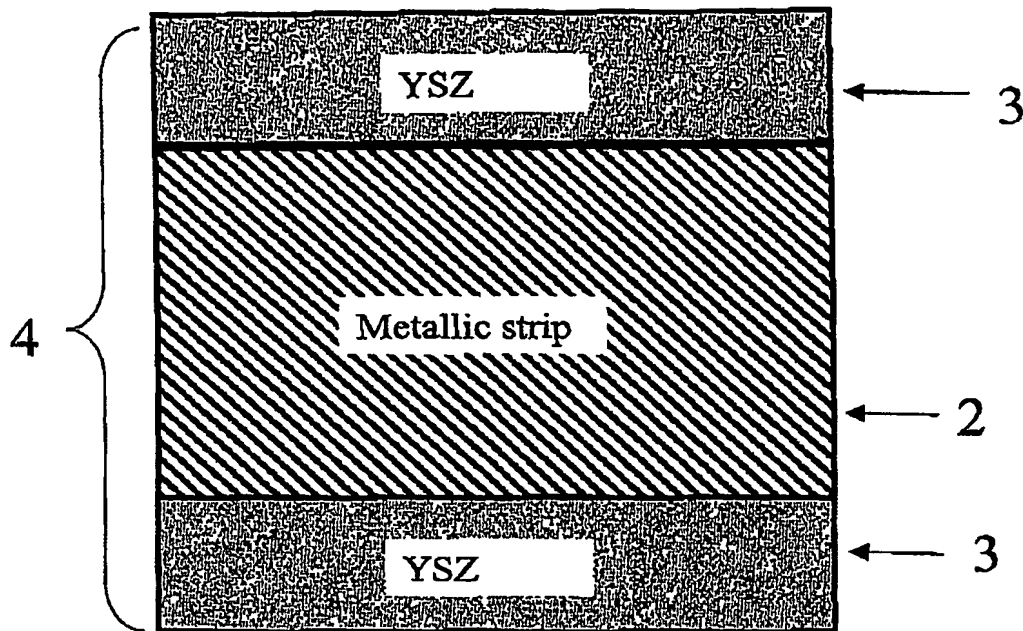


Fig. 2

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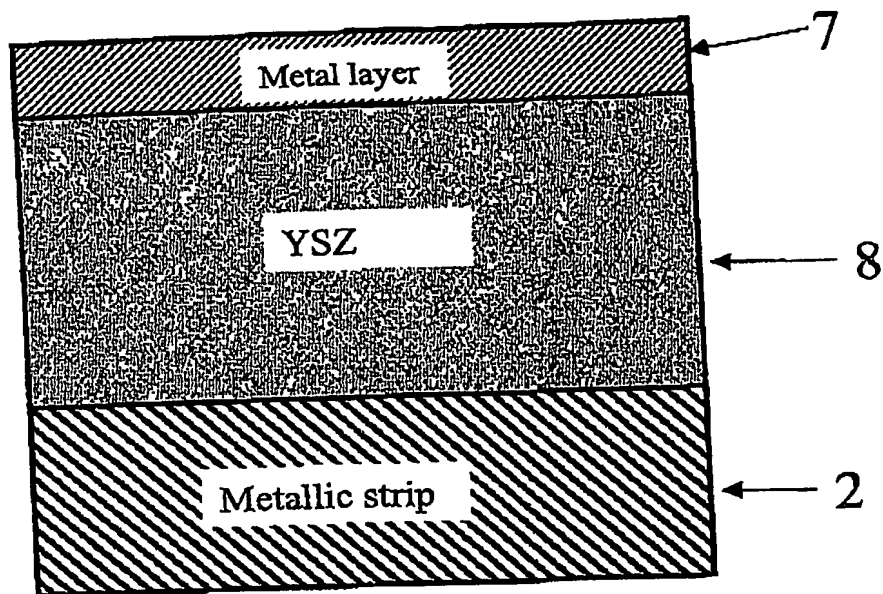


Fig. 4

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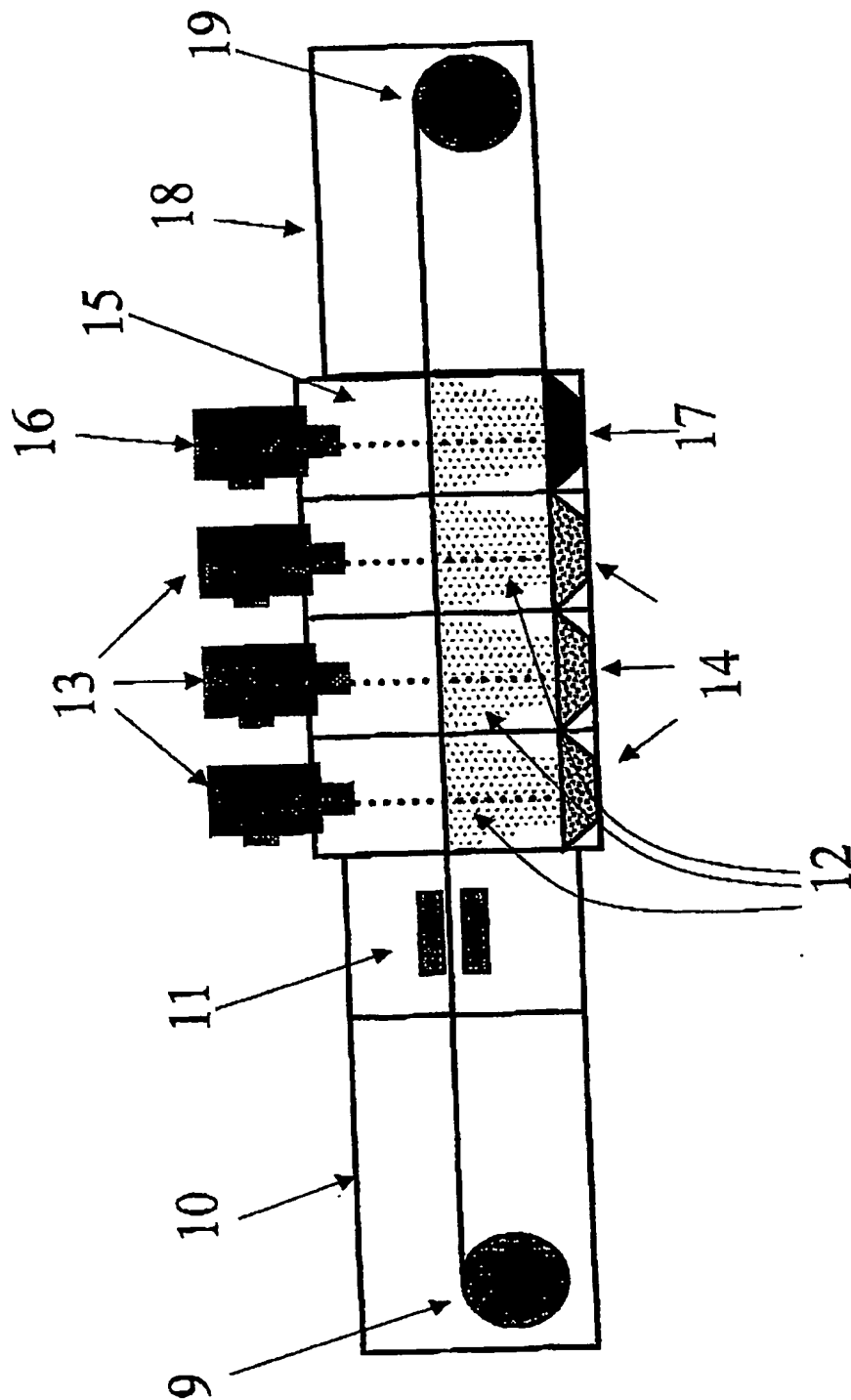


Fig. 5

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International application number: PCT/SE04/001810

International filing date: 03 December 2004 (03.12.2004)

Document type: Certified copy of priority document

Document details: Country/Office: SE
Number: 0303281-0
Filing date: 05 December 2003 (05.12.2003)

Date of receipt at the International Bureau: 07 January 2005 (07.01.2005)

Remark: Priority document submitted or transmitted to the International Bureau in compliance with Rule 17.1(a) or (b)



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